

Electrical control of intrinsic nonlinear Hall effect in antiferromagnetic topological insulator sandwiches

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A nonlinear Hall effect (NHE) can originate from the quantum metric mechanism in antiferromagnetic topological materials with PT symmetry, which has been experimentally observed in MnBi_2Te_4 . In this paper, we propose that breaking PT symmetry via external electric fields can lead to a dramatic enhancement of NHE, thus allowing for an electric control of NHE. Microscopically, this is because breaking PT symmetry can lift the spin degeneracy of a Kramers pair, giving rise to additional contributions within one Kramers pair of bands. We demonstrate this enhancement through a model Hamiltonian that describes an antiferromagnetic topological insulator sandwich structure.

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I. INTRODUCTION

Integrating magnetism into topological insulators (TIs) can break time reversal (T) symmetry and lead to the emergence of magnetic topological phases, e.g., quantum anomalous Hall (QAH) insulators [1–8] and axion insulators (AIs) [9–12]. Magnetism has been successfully achieved in TIs by either doping magnetic impurities, e.g., Cr- and/or V-doped (Bi, Sb)₂ Te_3 , or growing a stoichiometric antiferromagnetic topological compound, MnBi_2Te_4 . When ferromagnetism is achieved in TI films, both surface states are gapped, leading to the QAH effect [1,8,13,14]. The quantized Hall response for QAH states has been unambiguously observed in several systems, including magnetically doped TIs [3–6], MnBi_2Te_4 films [7], and twisted graphene and transition metal dichalcogenide materials [15–24]. When two surface states of TI films are gapped by antiferromagnetic (AFM) alignment of magnetization, which can be achieved in a magnetic TI sandwich structure with AFM alignment at two surfaces (dubbed as “AFM TIs” below), as shown in Fig. 1(a), or in even septuple layers (SLs) of MnBi_2Te_4 films [25,26], the AI phase was theoretically predicted and can host a quantized magnetoelectric response [10,27–29]. A zero Hall plateau observed in these AFM TIs [11,12] provides evidence for the AI phase. Optical experiments have also been studied in AFM TIs to explore the axion electrodynamics of the AI phase [30–34].

Recently, quantized topological and nonquantized geometric responses have been generalized to the nonlinear regime in topological materials [35–44]. A notable example is the nonlinear Hall effect (NHE), which describes the Hall current response at the nonlinear order of electric fields. There are two major intrinsic geometric mechanisms for NHE, the Berry curvature dipole [45–48] and the quantum metric

dipole [49–52]. These two mechanisms have different symmetry properties. The Berry curvature dipole-induced NHE can exist in a T -symmetric system, but is forbidden by PT symmetry, where P is inversion. This is because PT symmetry guarantees the double degeneracy of all bands at each momentum. Due to its similarity to Kramers’ theorem for T -symmetric systems [53,54], these spin degenerate bands are dubbed “Kramers pairs” below. As a result, the Berry curvature, as well as the Berry curvature dipole, has to vanish at each momentum in the Brillouin zone (BZ). In contrast, the quantum metric dipole (also called “intrinsic NHE” [49,52]) requires the T breaking, but it can exist in a PT -symmetric system. The AFM TIs can possess PT symmetry but break both P and T symmetry due to the AFM order, and thus provide an ideal platform to examine the intrinsic NHE induced by a quantum metric. Recently, intrinsic NHE has been experimentally observed in even SLs of MnBi_2Te_4 films [55,56]. The quantum metric mechanism requires breaking both T and P but also occurs in PT -breaking systems. Our main objective is to understand the dependence of intrinsic NHE on the PT breaking, achieved by an out-of-plane electric field.

In this paper, we study the NHE in a model Hamiltonian of AFM TIs under electric fields in Figs. 1(a) and 1(b). Inversion symmetry breaking by electric fields can lift the spin degeneracy of a Kramers pair of bands. Although these two spin bands are no longer degenerate in energy, we continue using the terminology “Kramers pair” to denote them. In PT -symmetric systems, only the contribution between different Kramers pairs of bands (dubbed “inter-Kramers pairs” below) exist for the NHE. Our main result here is to show additional NHE contributions from two spin bands within one Kramers pair (dubbed “intra-Kramers pair” below) can emerge when the inversion symmetry breaking is strong enough so that the energy splitting between the two spin bands is larger than disorder broadening. Furthermore, we find the intra-Kramers-pair NHE contribution can dominate over the inter-Kramers-pairs

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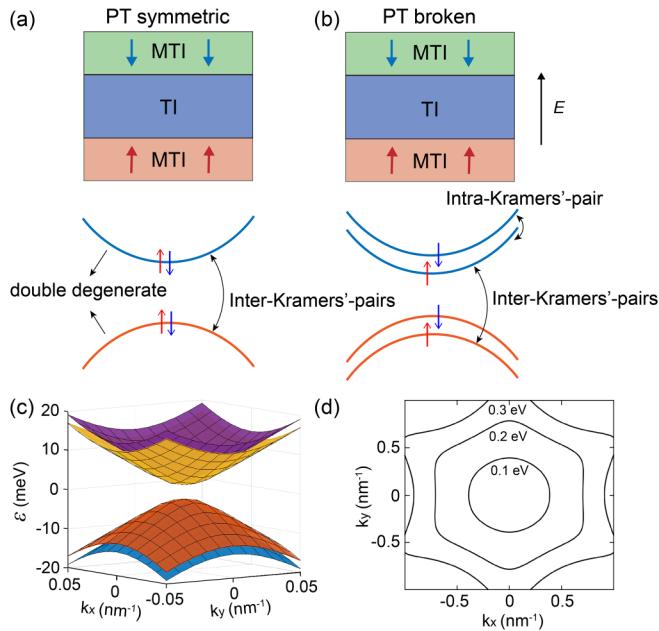


FIG. 1. (a) PT -symmetric magnetic TI sandwich structure. Each band is doubly degenerate due to the PT symmetry and the quantum metric dipole only arises between different Kramers pairs of bands. (b) When an external electric field breaks PT symmetry, the Kramers pairs split in energy, giving rise to additional contributions between two bands within one Kramers pair. (c) The energy dispersion for $t = 2$ meV and $V_0 = 1$ meV. (d) Fermi-surface contours of the lowest conduction band at the Fermi energies $\varepsilon_f = 0.1, 0.2$, and 0.3 eV.

NHE contribution in the thin-film limit when the top and bottom surface states are strongly hybridized. We predict an enhancement of the intrinsic NHE in AFM TIs due to the PT -symmetry breaking.

II. MODEL HAMILTONIAN AND SYMMETRY FOR AFM TIs

We consider a model Hamiltonian for the AFM TI sandwiches, as shown in Fig. 1(a), where the top and bottom surface states open the gaps with opposite signs. We assume the Fermi energy is within the TI bulk, so the low-energy effective Hamiltonian for two surface states reads

$$H = v_f(k_y\sigma_x - k_x\sigma_y)\tau_z + m\sigma_z\tau_z + \lambda(k_+^3 + k_-^3)\sigma_z\tau_z + t\tau_x + V_0\tau_z, \quad (1)$$

where σ_i and τ_i ($i = x, y, z$) are Pauli matrices in the spin and surface states basis, v_f is the Fermi velocity, m is the exchange coupling strength, λ is the hexagonal warping coefficient [57], and $k_{\pm} = k_x \pm ik_y$. We choose the parameters to be $v_f = 2.55$ eV Å, $\lambda = 125$ eV Å 3 , and $m = 1$ meV [57]. V_0 is the asymmetric potential created by the out-of-plane electric field E , $V_0 = eEd$, where d is the TI film thickness. The coupling parameter t describes the hybridization strength between the top and bottom surface states, which quickly decays as the film thickness d increases and is chosen in the range of 0–10 meV [58–61].

The model Hamiltonian breaks $P = \tau_x$ and $T = i\sigma_y K$ symmetries, and preserves $C_{3z} = e^{-i\frac{\pi}{3}\sigma_z}$ and $M_x T = -i\sigma_z K$

symmetries. In particular, the exchange coupling term breaks P , T , $M_x = i\sigma_x$, and $M_y = i\sigma_y$ symmetries, the hexagonal warping term breaks the full rotational symmetries down to the C_{3z} symmetry, and the asymmetric potential term V_0 breaks P and PT symmetries. When the asymmetric potential is absent, the system is PT symmetric. The symmetry properties of this system also give a strong constraint on the form of nonlinear conductivity σ_{abc} , defined by $j^a = \sigma_{abc}E^bE^c$, where $a, b, c = x, y$. From the symmetry analysis shown in the Supplemental Material [62] (see also Refs. [63–67] therein), $M_x T$ requires $\sigma_{yyy} = \sigma_{yxx} = \sigma_{xyx} = \sigma_{xxy} = 0$ while C_{3z} requires $\sigma_{xyy} = \sigma_{xyx} = \sigma_{yyx} = -\sigma_{xxx}$. Therefore, σ_{xyy} is the only independent component.

The eigenenergies of the Hamiltonian can be solved as $\varepsilon_{n\mu} = n\sqrt{t^2 + (A + \mu V_0)^2}$, where $n, \mu = \pm$ and $A = \sqrt{v_f^2 k^2 + [m + 2\lambda k_x(k_x^2 - 3k_y^2)]^2}$, where n is the index for different sets of Kramers pairs and μ labels two spin states in one Kramers pair. When $V_0 = 0$, there are two sets of degenerate Kramers pairs with the eigenenergies $\varepsilon_{\pm} = \pm\sqrt{A^2 + t^2}$. Such degeneracy is broken by a nonzero V_0 in Fig. 1(c), where the energy dispersion is calculated for $t = 2$ meV and $V_0 = 1$ meV. Figure 1(d) depicts the Fermi-surface contours of the lowest conduction band at different energies, where the hexagonal warping effect is visible for a large momentum k .

III. QUANTUM-METRIC-INDUCED NHE IN PT -SYMMETRIC AND PT -BREAKING SYSTEMS

Since the Berry curvature dipole is forbidden by C_{3z} [45,68], it is excluded in our model even when PT symmetry is broken. Therefore, we focus on the intrinsic NHE. The intrinsic nonlinear Hall conductivity can be written as (see Supplemental Material [62])

$$\sigma_{xyy} = -\frac{e^3}{\hbar} \sum_{n\mu, mv} \int \frac{d^3k}{(2\pi)^3} f_{n\mu} [\partial_x (\alpha_{n\mu, mv} g_{n\mu, mv}^{yy}) + \partial_y (\beta_{n\mu, mv} g_{n\mu, mv}^{xy})], \quad (2)$$

where $\partial_a = \frac{\partial}{\partial k_a}$ and $f_{n\mu} = \frac{1}{e^{(\varepsilon_{n\mu} - \varepsilon_f)/\Gamma} + 1}$ is the Fermi distribution function, with the eigenenergy $\varepsilon_{n\mu}$, the Fermi energy ε_f , and the temperature broadening $\Gamma = k_B T$. The band-resolved quantum metric reads [50]

$$g_{n\mu, mv}^{ab} = \mathcal{A}_{n\mu, mv}^a \mathcal{A}_{mv, n\mu}^b + \mathcal{A}_{n\mu, mv}^b \mathcal{A}_{mv, n\mu}^a, \quad (3)$$

where $\mathcal{A}_{n\mu, mv}^a = \langle n\mu | i\partial_a | mv \rangle$ is the Berry connection, and $|n\mu\rangle$ is the eigenwave function of the Hamiltonian. The remaining dependence on disorder broadening $\Delta_{\tau} = \hbar/\tau$ with the relaxation time τ in the intrinsic conductivity is via the functions α and β , defined as

$$\alpha_{n\mu, mv} = \text{Re} \left[\frac{\varepsilon_{n\mu, mv}}{\Delta_{\tau}(i\varepsilon_{n\mu, mv} + \Delta_{\tau})} - (n\mu \leftrightarrow mv) \right], \quad (4)$$

$$\beta_{n\mu, mv} = \text{Re} \left[\frac{\varepsilon_{n\mu, mv}}{i\varepsilon_{n\mu, mv} + \Delta_{\tau}/2} \left(\frac{1}{i\varepsilon_{n\mu, mv} + \Delta_{\tau}} + \frac{1}{\Delta_{\tau}} \right) - (n\mu \leftrightarrow mv) \right]. \quad (5)$$

This dependence becomes significant whenever the energy difference $\varepsilon_{n\mu, mv} = \varepsilon_{n\mu} - \varepsilon_{mv}$ is of the order of Δ_{τ} .

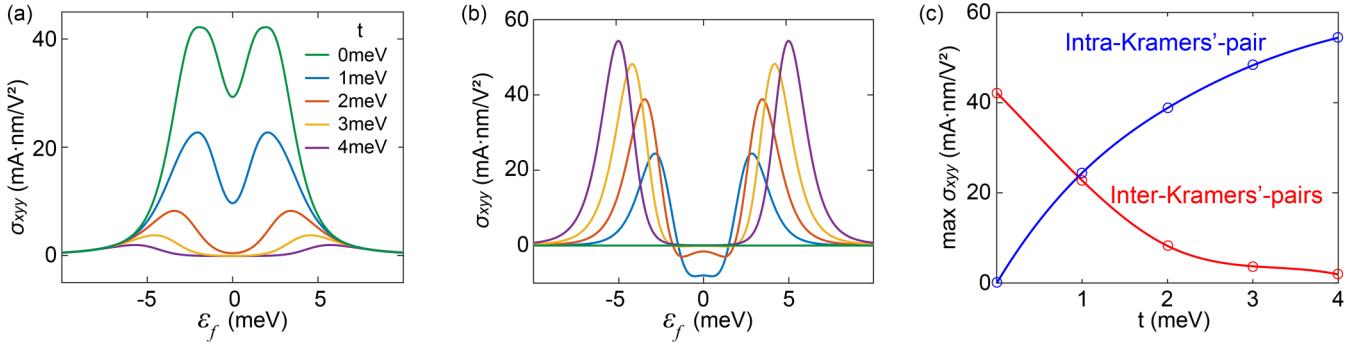


FIG. 2. (a) $\sigma_{xy}^{\text{inter}}$ as a function of Fermi energy ε_f for the inter-Kramers-pairs contribution at $V_0 = 2$ meV, $\Gamma = 0.6$ meV, and $t = 0, 1, 2, 3$ and 4 meV. (b) $\sigma_{xy}^{\text{intra}}$ as a function of Fermi energy ε_f for the intra-Kramers-pair contribution with different t . (c) The maximum value of $\sigma_{xy}^{\text{inter}}$ and $\sigma_{xy}^{\text{intra}}$ with respect to Fermi energy ε_f as a function of coupling coefficient t .

For the PT -symmetric case, the two spin bands within one Kramers pair ($n = m$) are degenerate so that $\varepsilon_{n\mu,nv} = 0$ and thus $\alpha_{n\mu,nv} = \beta_{n\mu,nv} = 0$. Therefore, the degenerate states within one Kramers pair give no contribution. We consider the case when the energy difference between different sets of Kramers pairs is much larger than the disorder level, i.e., $\varepsilon_{n\mu,mv} \gg \Delta_\tau$ ($n \neq m$), and can apply the expansion

$$\frac{1}{i\varepsilon_{n\mu,mv} + \Delta_\tau} = \frac{1}{i\varepsilon_{n\mu,mv}} + \frac{\Delta_\tau}{\varepsilon_{n\mu,mv}^2} + O(\Delta_\tau^2). \quad (6)$$

Up to the first order in Δ_τ , we find $\alpha_{n\mu,mv} = \frac{2}{\varepsilon_{n\mu,mv}}$ and $\beta_{n\mu,mv} = -\frac{1}{\varepsilon_{n\mu,mv}}$ for $n \neq m$, which leads to

$$\sigma_{xy} = -\frac{e^3}{\hbar} \sum_{n\mu} \int_k f_{n\mu} (2\partial_x G_{n\mu}^{yy} - \partial_y G_{n\mu}^{xy}), \quad (7)$$

where $G_{n\mu}^{ab} = \sum_{mv} g_{n\mu,mv}^{ab} / \varepsilon_{n\mu,mv}$ with $m \neq n$. The derived NHE expression is only for the quantum metric between non-degenerate bands (“inter-Kramers pairs”), and is consistent with Ref. [50]. The result can be also be viewed from the point of view of semiclassical theory. The origin of the NHE is traced to systematic corrections to the Berry curvature and energy dispersion stemming from the dressing of operators due to the electric field. Semiclassically, $H \rightarrow H + e\mathbf{E} \cdot \mathbf{r}$. Invoking the $U(1)^N$ symmetry of the block Hamiltonian, it is possible to remove the gauge-dependent linear coupling via a unitary transformation $H' = e^{-S} H e^S$, with S fixed to remove the linear in \mathbf{E} contribution (see Ref. [50]). However, it should be noted that the semiclassical approach fixes the diagonal components of H' . It is also possible to construct off-diagonal elements of H' and hence $\nu' = \frac{\partial H'}{\partial \mathbf{k}}$. By allowing off-diagonal elements in the Boltzmann equation away from the clean limit, one recovers Eqs. (4) and (5). Importantly, in the limit where the relaxation τ only enters the diagonal part of the density function $f_{n\mu}$ (the standard semiclassical assumption), the result of the Boltzmann treatment and the approach presented here coincide completely.

In PT -breaking systems, the asymmetric potential V_0 splits the energy of two spin bands within one Kramers pair. When the energy difference between these two spin bands is much larger than the disorder level, i.e., $V_0 \gg \Delta_\tau$, the relaxation time approximation [Eq. (6)] is valid for any pairs of (n, μ) and (m, v) and thus $\alpha_{n\mu,mv} = \frac{2}{\varepsilon_{n\mu,mv}}$ and $\beta_{n\mu,mv} = -\frac{1}{\varepsilon_{n\mu,mv}}$ for

both intra-Kramers pairs ($n = m$) and inter-Kramers pairs ($n \neq m$). We then obtain a similar expression as Eq. (7), but the summation over m in $G_{n\mu}^{ab} = \sum_{mv} g_{n\mu,mv}^{ab} / \varepsilon_{n\mu,mv}$ should also include $m = n$. Therefore, the quantum metric within one Kramers pair of bands (“intra-Kramers pair”) can also contribute to the NHE in addition to the inter-Kramers-pairs part.

IV. ELECTRIC FIELD CONTROL OF NHE

We numerically evaluate the NHE for the model Hamiltonian [Eq. (1)] based on Eq. (2). Figures 2(a) and 2(b) shows the Fermi energy ε_f dependence of the inter-Kramers-pair contribution $\sigma_{xy}^{\text{inter}}$ and the intra-Kramers-pair contribution $\sigma_{xy}^{\text{intra}}$ at different coupling coefficients t , respectively, at $V_0 = 2$ meV, $\Gamma = 0.6$ meV, and assuming the disorder level is very low ($V_0 \gg \hbar/\tau$). For both components, σ_{xy} displays the same sign in the electron and hole doping regions. The intra-Kramers-pair contribution $\sigma_{xy}^{\text{intra}}$ vanishes for $t = 0$ meV, which indicates that the interlayer hybridization term is crucial for the nonzero quantum metric between two bands in one Kramers pair. Furthermore, $\sigma_{xy}^{\text{intra}}$ increases with t while the inter-Kramers-pairs contribution $\sigma_{xy}^{\text{inter}}$ decreases, as illustrated in Fig. 2(c), which plots the maximum values $\max(\sigma_{xy}^{\text{intra}})$ and $\max(\sigma_{xy}^{\text{inter}})$ as a function of t . Here, the maximum refers to the peak value of $\sigma_{xy}^{\text{intra}}$ and $\sigma_{xy}^{\text{inter}}$ when varying with ε_f in Figs. 2(a) and 2(b). Therefore, the intra-Kramers-pair contribution $\sigma_{xy}^{\text{intra}}$ plays a more important role when the interlayer hybridization is stronger, i.e., when the sample thickness is thinner.

We summarize $\max(\sigma_{xy})$ as a function of V_0 in Fig. 3(a), in which the green curve depicts the variation of total $\max(\sigma_{xy})$, while the blue and red curves illustrate $\max(\sigma_{xy}^{\text{intra}})$ and $\max(\sigma_{xy}^{\text{inter}})$, respectively, at $t = 2$ meV and $\hbar/\tau = 0.5$ meV. The intra-Kramers-pair contribution $\max(\sigma_{xy}^{\text{intra}})$ is zero at $V_0 \sim 0$, and increases rapidly when V_0 is increasing. In contrast, the inter-Kramers-pairs contribution $\max(\sigma_{xy}^{\text{inter}})$ almost remains constant with increasing V_0 . Thus, one can divide the variation of $\max(\sigma_{xy})$ into three regions for a fixed disorder strength. When $V_0 \ll \hbar/\tau$, $\max(\sigma_{xy}^{\text{intra}})$ is close to zero and $\max(\sigma_{xy}^{\text{inter}})$ dominates. When $V_0 \sim \hbar/\tau$, $\max(\sigma_{xy}^{\text{intra}})$ increases rapidly with V_0 , while $\max(\sigma_{xy}^{\text{inter}})$ exhibits a small decrease.

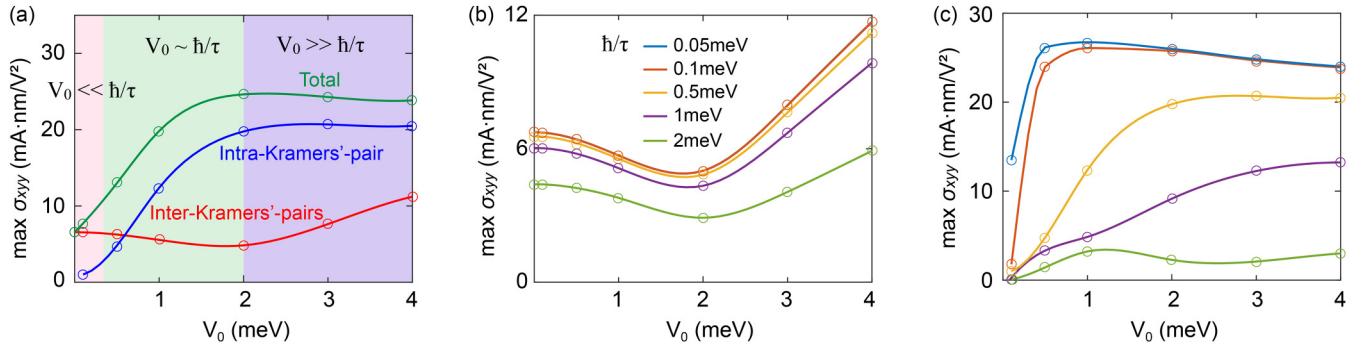


FIG. 3. (a) The maximum value of σ_{xy} for the intra-Kramers-pair (blue), inter-Kramers-pairs (red), and total (green) contributions as a function of asymmetric potential V_0 at $t = 2$ meV and $\hbar/\tau = 0.5$ meV. (b) The maximum value of $\sigma_{xy}^{\text{inter}}$ as a function of asymmetric potential V_0 at different disorder levels \hbar/τ for the inter-Kramers-pairs contribution at $t = 2$ meV. (c) The maximum value of $\sigma_{xy}^{\text{intra}}$ as a function of V_0 for the intra-Kramers-pair contribution at $t = 2$ meV.

When $V_0 \gg \hbar/\tau$, $\max(\sigma_{xy}^{\text{intra}})$ saturates while $\max(\sigma_{xy}^{\text{inter}})$ reveals an upturn. Figures 3(b) and 3(c) show the $\max(\sigma_{xy}^{\text{inter}})$ and $\max(\sigma_{xy}^{\text{intra}})$ as a function of V_0 for different \hbar/τ . The above scenario for the division of three regions generally remains valid for different \hbar/τ values. Furthermore, with increasing \hbar/τ , both $\max(\sigma_{xy}^{\text{inter}})$ and $\max(\sigma_{xy}^{\text{intra}})$ are reduced.

V. CONCLUSION

To summarize, we showed the enhancement of the intrinsic NHE in AFM TI sandwiches via the breaking of inversion symmetry. The intrinsic NHE has been observed for even SLs of MnBi_2Te_4 in two recent experiments [55,56], and the displacement field dependence of the NHE has been measured. As discussed previously, the amount of enhancement is affected by the film thickness as well as the disorder level in the system. In Ref. [55], a small enhancement of the NHE was reported as the displacement field increases. The conductivity in this experiment is $\sigma_{xx} \approx 14$ mS at a carrier density $n_e = 3 \times 10^{12}$ cm⁻², and from $\tau = \frac{m^* \sigma_{xx}}{e^2 n_e}$ with the electron effective mass $m^* \approx 0.1 m_e$ [69], we estimate the disorder level to be $\hbar/\tau \sim 0.4$ meV. However, the experiment was performed in 6 SL MnBi_2Te_4 , of which the hybridization strength between two surface states is considerably small [58–61], thus suppressing the intra-Kramers-pair contribution, as well as the enhancement of NHE. In Ref. [56], on the other hand, very little or no increase of the NHE was observed in the displacement field dependence measurement. We estimate the disorder level as $\hbar/\tau \sim 20$ meV with $\sigma_{xx}/n_e \approx 9 \times 10^{-11}$ $\mu\text{S cm}^2$ and strong disorder scattering can greatly suppress the NHE enhancement.

The scaling analysis between the nonlinear Hall conductivity and the longitudinal conductivity by varying temperatures has been used to distinguish the intrinsic NHE, which is the sole contribution that is independent of relaxation time τ in the weak disorder limit, from other extrinsic mechanisms, e.g., skew scattering and side jump [49,56,70–72], with strong dependence on τ . As our NHE formula Eq. (2) is beyond the weak disorder limit, the relaxation time τ dependence of the intrinsic NHE is found in Figs. 3(b) and 3(c), when the

disorder broadening is comparable to band energy splitting. We note in both experiments [55,56] the NHE shows very little dependence of τ when varying temperatures. As the NHE only appears below the Néel temperature ~ 24 K [73], we can estimate the change of relaxation time to be $\frac{\delta\tau}{\tau} \sim 20\%$ within this temperature range. From Figs. 3(b) and 3(c), a significant change of NHE can only occur when τ is changed several times. Thus, a 20% variation of τ can only give a negligible change of NHE, while more feasible control is through a displacement field [55].

In our calculations, the value of NHE is around the order of 10 mA nm/V², while the experimental values reported in Refs. [55,56] are both ~ 100 mA nm/V², one order larger than the calculated value. To explain this discrepancy, it was proposed that the quantum metric in experiments might be enhanced by the modified surface band structure of MnBi_2Te_4 [56]. As disorder scattering is strong in Ref. [56], a full quantum mechanical treatment of the disorder effect beyond the relaxation time approximation [70,71,74,75] is required. Furthermore, the edge transport may also give rise to the NHE for the Fermi energy close to the band edges [76,77], which is beyond the current theoretical formalism.

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